



Docket No.: 073759-0015

PATENT

IFW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of	:	Customer Number: 20277
	:	
Yasuhiro OKUDA, et al.	:	Confirmation Number: 2653
	:	
Application No.: 10/559,580	:	Group Art Unit: 1774
	:	
Filed: December 05, 2005	:	Examiner: Not yet assigned
	:	

For: PERFORATED POROUS RESIN BASE AND PRODUCTION PROCESS OF POROUS
RESIN BASE WITH INNER WALL SURFACES OF PERFORATIONS MADE CONDUCTIVE

INFORMATION DISCLOSURE STATEMENT

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

The relevance of each non-English language reference is discussed in the present specification.

10/559,580

Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,


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**Please recognize our Customer No. 20277
as our correspondence address.**

INFORMATION DISCLOSURE CITATION IN AN APPLICATION (PTO-1449)				ATTY. DOCKET NO. 073759-0015		SERIAL NO. 10/559,580	
				APPLICANT Yasuhiro OKUDA, et al.			
				FILING DATE December 05, 2005		GROUP Not Yet Assigned	
U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code ₂ (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
		US 5,858,505	01/12/1999	Moen et al.			
		US					
FOREIGN PATENT DOCUMENTS							
EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes - Number - Kind Codes (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Figures Appear	Translation	
						Yes	No
		JP 04-242010 A	08/28/1992	SONY CHEM CORP		JAPAN (w/ English abstract)	
		JP 09-320667 A	12/12/1997	JAPAN SYNTHETIC RUBBER CO., LTD.		JAPAN (w/ English abstract)	
		JP 02-049385 A	02/19/1990	CANON INC.	Corresponds to US 4,926,549 and US 5,216,807	JAPAN (w/ English abstract)	
		JP 2003-022849 A	01/24/2003	CITIZEN ELECTRONICS CO., LTD.		JAPAN (w/ English abstract)	
		JP 08-506777 A	07/23/1996		Corresponds to WO 94/19170 and US 5,858,505		X
		WO 94/19170	09/01/1994	W.L. GORE & ASSOCIATES, INC.	Corresponds to JP 08-506777 and US 5,858,505	X	
		JP 2004-265844 A	09/24/2004	SUMITOMO ELECTRIC IND. LTD.			
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.					
		"Electronics Jisso Gijutsu Koza (Elementary Course of Mounting Techniques in Electronics), Vol. 1, Introduction" Edited by Association of Hybrid Microelectronics, Kogyo Chosakai Shuppan, 07/07/1998, Pages 203-209.					JAPAN (w/ Excerpt Translation)
		"Maikuro Kako Gijutsu (Microworking Techniques)" Edited by The Editorial Committee of Microworking Techniques, The Nikkan Kogyo Shinbun, Ltd., 09/30/1988, Pages 8-13 and 168-175.					JAPAN (w/ Excerpt Translation)
EXAMINER				DATE CONSIDERED			

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.